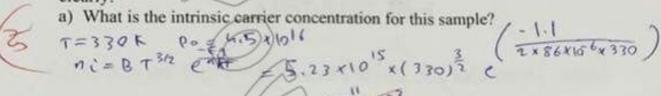
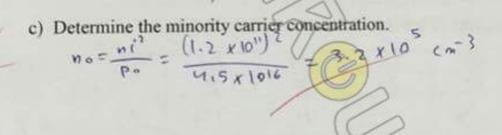
Some useful Constants:		86
$B(Si) = 5.23 \times 10^{15} cm^{-3} K^{-3/2}$	$E_a(Si) = 1.1 eV$	$k = 68 \times 10^{-6} eV/K$
$e = 1.6 \times 10^{-19} C$		
$\mu_n(Si) = 1350 \ cm^2/V - s$	$\mu_p(Si) = 480 \text{ cm}^2/V - s$	

Question 1: [20-points] |5

A Silicon semiconductor material is to be designed at temperature 330K, such that the majority carrier hole concentration is 4.5×10^{16} cm⁻³. Answer the following questions



b) Should donor or acceptor impurity atoms be used to achieve this concentration? acceptor impulity should be used



d) An applied electric field E = 15 V/cm is applied to the designed sample, determined to the designed sample, determined to the designed sample. the drift current if you know that the cross sectional area for it is $2 \times 10^{-4} cm^2$.

the drift current if you know that the cross sectional area for it is
$$2 \times 10^{-4} \text{ cm}^2$$
.

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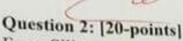
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e) True or False: As impurity concentration increase, the electron mobility decrease. False



For a Silicon pn junction, let $N_a = 5 \times 10^{15}$ and $N_d = 8 \times 10^{17}$ answer the following

a) Determine the built-in potential barrier of the generated pn junction at room ni((si) = 1.5x1010 temperature.

Voi= VT (n (NaNd)

= 0.028 In (5x1015 x8x1017)

b) If this pn junction diode is operating in forward-bias region, determine the increase in forward bias voltage that will cause a factor of 22 increase in current.

 $\frac{T\rho_2}{T\rho_1} = e^{\left(\frac{V\rho_2 - V\rho_1}{V\tau}\right)}$

DV = VT In (ID2)

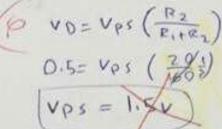
= 0.026 In (22)

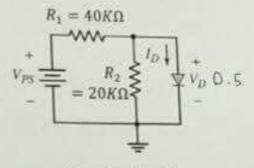
DV = 0.08 V - increase in forward bias voltage

Question 3: [20-points]

Part 3.1: For the diode circuit shown in Figure Q.3.Part 1, it has a reverse-saturation current of $I_S = 5 \times 10^{-13}$, assume T = 300K, answer the following questions:

a) What is the input voltage V_{PS} that will produce $V_D = 0.5V$.





b) Determine the I_D value

$$I_0 = I_s (e^{\frac{\sqrt{2}}{\sqrt{1}}} - 1)$$

= $5 \times 10^{-13} (e^{\frac{0.5}{0.076}} - 1)$
 $I_0 = 1.12 \times 10^{-4}$

Figure Q.3.Part 1

Part 3.2: For the circuit shown in Q.3.Part 2, assume $V_y = 0.6V$, find I and V_o .

$$T = \frac{12 - 0.6}{22 \text{ K.A.}} = 0.518 \text{ mA}$$

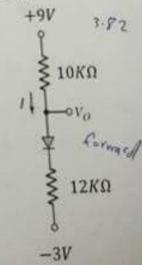


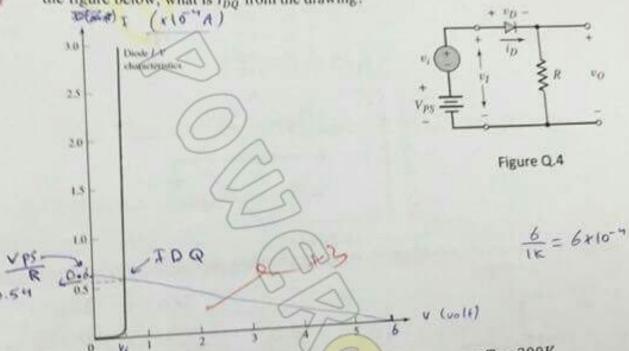
Figure Q.3.Part 2

Question 4: [20-points]

105/R

For the circuit shown in Figure Q.4, at room temperature, assume circuit parameters: $V_{PS} = 6V$, and $R = 1k\Omega$. The diode $V_{\gamma} = 0.6V$. A sinusoidal voltage is superimposed on V_{PS} such that $v_i = 0.2 \sin(\omega t)$. As you learned in the class, do the following:

a) For this circuit, draw the related load line over the diode characteristic curve given in the figure below, what is I_{DQ} from the drawing?



Calculate the small-signal diode diffusion resistance, assume
$$T = 300K$$
.

$$T = \frac{V\tau}{TDQ} = \frac{0.026}{5.4 \times 10^3} = 4.814.0$$

$$T = \frac{V\tau}{TDQ} = \frac{0.026}{5.4 \times 10^3} = 4.814.0$$

c) What is the "only" ac component of the output voltage
$$v_0$$
?

$$(id = \frac{vi \times R}{v_0t + R} = \frac{0.2 \sin(wt) \times R}{(u.8 + 1 K)} = \frac{1.99 \times 10^{-4} R}{(u.8 + 1 K)} \sin(wt) \times R$$

$$v_0 = 0.199 \sin(wt) \times R$$

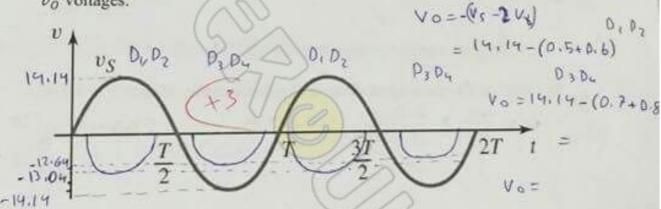
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Question 5: [20-points]

For the full-bridge rectifier circuit shown in Figure Q.5, if the turns ratio of the attached transformer is 22, the input voltage v_i was $220V_{RMS}$, each diode has the following cut-in voltages shown in the table, answer the following questions:

		100 TH 500 T	
$N_1:N_2$	D1 $V_{\gamma} = 0.5$ D2 $V_{\gamma} = 0.6$ D3 $V_{\gamma} = 0.7$ D4 $V_{\gamma} = 0.8$	$V_{S} = \frac{270 \times 62}{22}$ $\frac{N_{1}}{N_{2}} = 22$	1010 = 14/14 = 7882624, 6
	v _S -v _O +), }_	
£3.8	Figure Q.5	D ₄ V ₅₌₁₄	×5

a) Draw the output voltage v₀ on the graph below showing the real values of v_s and v₀ voltages.



b) Determine the peak inverse voltage rating for each diode in the circuit.

$$PIV = V_5 - V_8$$

$$D_1 = 19.14 - 0.75 = 13.64$$

$$P_2 : 14.14 - 0.76 = 13.54$$

$$P_3 : 14.14 - 0.77 = 13.44$$

$$P_3 : 14.14 - 0.77 = 13.44$$

$$P_4 : 14.14 - 0.78 = 13.34$$